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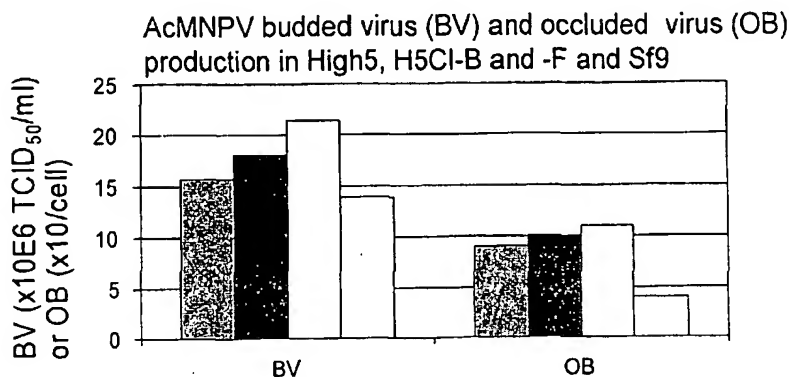
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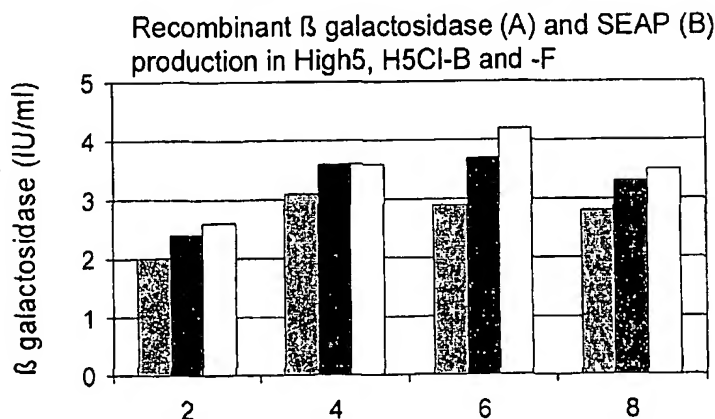
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*[Continued on next page]*

**(54) Title:** IMPROVED CLONAL CELL LINES DERIVED FROM BTI-TN-5B1-4



**(57) Abstract:** Improved insect cell lines, two of which are designated H5CL-B and H5CL-F (both of which are derived from the parental cell line BTI-TN-5B1-4, ATCC CRL 10859), possess the properties of increased production of baculovirus particles, increased expression of foreign proteins using a baculovirus expression system, and increased resistance to cell culture stress, relative to the parental cell line.



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